

COURSE DATA

Data Subject			
Code	44420	ALEE	
Name	Physical nanomanufacturing techniques		
Cycle	Master's degree		
ECTS Credits	3.0		
Academic year	2021 - 2022		
Study (s)			
Degree		Center	Acad. Period year
	ecular Nanoscience and	Faculty of Chemistry	1 First term
Nanotechnology			
	and and a start and a start and a start		
Nanotechnology Subject-matter Degree	1525257	Subject-matter	Character
Subject-matter Degree	ecular Nanoscience and	Subject-matter 4 - Physical nanomanufacturing techniques	Character Obligatory
Subject-matter Degree 2208 - M.D. in Mole	ecular Nanoscience and	4 - Physical nanomanufacturing	
Subject-matter Degree 2208 - M.D. in Mole Nanotechnology	ecular Nanoscience and	4 - Physical nanomanufacturing	

SUMMARY

The aim is that students learn basic concepts related to nanofabrication based on a bottom-up approach. Particular focus will be devoted to the possibilities and limits of the lithographic techniques, as nanofabrication tools.

PREVIOUS KNOWLEDGE

Relationship to other subjects of the same degree

There are no specified enrollment restrictions with other subjects of the curriculum.



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Other requirements

There are no specified enrollment restrictions with other subjects of the curriculum.

OUTCOMES

2208 - M.D. in Molecular Nanoscience and Nanotechnology

- Students should apply acquired knowledge to solve problems in unfamiliar contexts within their field of study, including multidisciplinary scenarios.
- Students should be able to integrate knowledge and address the complexity of making informed judgments based on incomplete or limited information, including reflections on the social and ethical responsibilities associated with the application of their knowledge and judgments.
- Students should demonstrate self-directed learning skills for continued academic growth.
- Students should possess and understand foundational knowledge that enables original thinking and research in the field.
- To possess the necessary knowledge and abilities to continue with future studies in the PhD program in Nanoscience and Nanotechnology.
- For students from field of knowledge (e.g. chemistry) to be able to scientifically communicate and interact with colleagues from another field (e.g. physics) in the resolution of problems laid out by the Molecular Nanoscience and Nanotechnology.
- To know the methodological approaches used in Nanoscience.
- To know the main techniques for molecular systems nanofabrication.

LEARNING OUTCOMES

The aim is that students acquire basic concepts related to a top-down approximation to nanofabrication. In particular, we will focus on the possibilities and limits of the different available lithographic techniques as tools for nanofabrication.

DESCRIPTION OF CONTENTS

1. Physical nanofabrication techniques.

1) Introduction: Lithographic techniques in the context of nanofabrication techniques.

- 2) Optical lithography
- 2.1.Basic processes and lift-off.
- 2.2. Thin film deposition of resists by spin-coatting.

2.3.Photoresist exposition through a mask: methods and resolution; techniques for resolution improvement; Photoresists: types, examples, evaluation parameters, chemically amplified photoresists.2.4. Limits and future of the technique.



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- 3) Etching techniques
- 3.1 Wet etching techniques
- 3.2 Dry etching techniques: reactive ion etching (RIE) and variants, sputtering, laser ablation, etc
- 3.3 Clean rooms.
- 4) Nanolithography by nanoimprinting and microcontact.
- 5.1. Microcontact printing.
- 5.2. Nanoimprint lithography (NIL) and variants: thermal NIL, room temperatura NIL, solvent-assisted
- NIL, step and flash NIL, etc
- 5.3. Molding of plastics: hot embossing, injection, etc..
- 5) Electron beam lithography
- 3.1 The scanning electron microscope
- 3.2 Interactions between electrons and matter
- 3.3 electron beam lithography
- 3.4 Applications and some examples
- 6) Scanning probe lithography
- 6.1 The force microscope
- 6.2 The variety of Scanning probe lithographies
- 6.3 Oxidation SPL
- 6.4 Thermal SPL
- 6.5 Applications: Silicon nanowire transistors; bimolecular sensors; molecular architectures.

7) The atomic force microscope in biology and material sciences

- 7.1 Operational principles
- 7.2 AFM modes
- 7.3 Forces and spatial resolution
- 7.4 High resolution imaging of soft matter
- 7.5 Nanomechanical and single molecule force spectroscopies
- 8) Focused Ion Beam Lithography and other direct patterning methods
- 8.1 Introduction to direct patterning Methods
- 8.2 Laser Beam Lithography
- 8.3 eBeam assited Patternning
- 8.4 Focused ion Beam Lithogrpahy



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WORKLOAD

ACTIVITY	Hours	% To be attended
Theory classes	15,00	100
Tutorials	5,00	100
Seminars	4,00	100
Other activities	2,00	100
Preparation of evaluation activities	39,00	0
Preparing lectures	10,00	0
TOTAL	75,00	

TEACHING METHODOLOGY

- Theory classes, participatory lectures
- Articles discussion.
- Chaired debate or discussion.
- Practical cases or seminar problems discussion.
- Seminars.
- Problems.
- Laboratory practices and demonstracions and visit to installations.
- Experts conferences.
- Attendance to courses, conferences and round tables.

EVALUATION

Written exam about the subject basic contents	70-90%
Attendance and active participation in seminars.	0-10%
Questions answering	10-20%



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REFERENCES

Basic

- From Instrumentation to Nanotechnology, J.W. Gardner, H.T. Hingle, Gordon & Breach Publishing Group, 1999.

- Micromachines & Nanotechnology: The Amazing New World of the Ultrasmall, David Darling, Silver Burdett Press, 1995.

- Zheng Cui (Author) Micro-Nanofabrication: Technologies and Applications; Higher Education Press; Springer; 2005.

- E. Menard et al. Micro- and Nanopatterning Techniques for Organic Electronic an optoelectronic system; Chem. Rev. 107, 1117, 2007.

- P. Rai-Choudhury (Ed) Handbook of Microlithography, Micromachining and Microfabrication, Vol. 1, SPIE Optical Engineering Press, Bellingham, WA, 1997

- Kazuaki Suzuki & Bruce W. Smith (Eds.)Microlithography: Science & Technology, 2nd Ed. (Optical Sci. and Eng.); CRC Press, 2007

- D. Xia, Z. Ku, S.C. Lee, and S.R.J. Brueck, Nanostructures and Functional Materials Fabricated by Interferometric Lithography, Adv. Mater. 23, 147 179 (2011).

Additional

· Fundamentals of microfabrication and nanotechnology. M.J. Madou, CRC Press (2011)

- Amplitude modulation AFM, R. Garcia, Wiley-VCH (2010)
- Scanning Probe Microscopy: The lab on a tip, E. Meyer, H. Hug, R. Bennewitz, Springer (2004)

- Advanced scanning probe lithography, R. Garcia, A.W. Knoll, E. Riedo, Nature Nanotechnology 9, 577-587 (2014)

ADDENDUM COVID-19

This addendum will only be activated if the health situation requires so and with the prior agreement of the Governing Council

1.1. Contenido /Contingut/ Content

Contents initially included in the teaching guide are maintained.

2. Volum de treball i planificació temporal de la docència

2. Volumen de trabajo y planificación temporal de la docencia



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2. Workload and teaching time planning

3. Metodología docente / Metodología docente/ Teaching Methodology

The workload of different teaching activities (theory classes, seminars and tutorials) is maintained.

The **theory classes**, which should have been taught intensively in Valencia during two weeks, are being recorded as a slide show with narration. This material will be available to students in a e-learning platform (Master Intranet, Moodle (Aula Virtual) or MSTeams) two weeks before the online lessons. Students will be informed how to access these classes.

All these lessons have a **seminar** part, which is planned to be given online by each professor using the common videoconference programs available in the participating universities (Blackboard collaborate, Teams, Zoom, etc.). This seminar part includes solving practical problems, questions and student doubts related to the subject. The attendance to these online videoconferences will be compulsory for all master students and will be recorded and uploaded in the e-learning platform. This part will be tentatively scheduled in the same period as in-person lectures.

Finally, person to person **tutorials** to answer questions / doubts will be available as in previous years through telephone, E-mail and, additionally, through chats in the e-learning platform.

4. Avaluació/Evaluación/ Evaluation

Given that this exam will be carried out by small groups of students in each university (maximum of 14 students in the University of Valencia) and they have been delayed to July, it will be attempted to do it "in person". If the face-to-face examination would not be possible, it will be carried out on-line using the e-learning platform videoconference.

'Questions answering' and 'Attendance and active participation in seminars' will be evaluated during the online seminars.

Students will be informed with at least 10 days in advance if the exams will be done inperson or on-line.



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5. Bibliografia/Bibliografía/Bibliography

Some of the recommended bibliography is available online. In case a student wants more detailed information on a specific topic, professors will provide it through scientific articles (to which the Universitites are subscribed or published with open-access), doctoral phD theses in public repositories, etc.

